Experimental and Computational Investigation of Lanthanide Ion Doping on BiVO₄ Photoanodes for Solar Water Splitting

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ABSTRACT

N-Type bismuth vanadate (BiVO₄) has emerged as one of the most promising photoanodes for use in water splitting photoelectrochemical cells in recent years. However, its photoelectrochemical properties may be further enhanced by optimizing its bandgap and its charge transport properties. Doping at the V⁵⁺ and O²⁻ sites of BiVO₄ has proven to be an effective strategy to alter the oxide electronic band structure and/or charge transport properties, but the effect of doping at the Bi³⁺ site is not nearly as well understood. In this study, we performed a combined experimental and theoretical study of BiVO₄ doped with lanthanide (Ln) elements (La, Ce, Sm, and Yb) at the Bi³⁺ site, and we elucidated the effect of doping on the electronic band structure and charge transport properties of BiVO₄. Furthermore, we performed density-functional theory calculations to investigate the combined effect of the Ln doping and oxygen vacancies, which are intrinsic defects in BiVO₄. Our results showed that for some cases the simultaneous consideration of Ln doping and O vacancy leads to changes that cannot be obtained by the sum of the changes caused by Ln doping alone and O vacancy alone, which was critical to understanding the experimental results. The various ways that the Ln dopants modified the electronic band structure and charge transport properties of BiVO₄ demonstrated in this study can provide useful guidelines for the tuning of the composition of oxide-based photoelectrodes.
1. Introduction

Practical solar hydrogen production using water splitting photoelectrochemical cells (PECs) critically depends on the cost of solar hydrogen production.\textsuperscript{1-3} One of the approaches to lowering the production cost of solar hydrogen production is the development of oxide-based polycrystalline semiconductors for use as photoelectrodes in a PEC device, due to generally cheaper costs of the raw materials and of electrode processing.\textsuperscript{4-5} Among oxide-based semiconductors, n-type monoclinic bismuth vanadate (BiVO\textsubscript{4}) has emerged as a promising candidate for use as a photoanode in PECs.\textsuperscript{6-7} When fabricated as polycrystalline electrodes, BiVO\textsubscript{4} is shown not to suffer from serious bulk and surface electron-hole recombination unlike other oxide-based photoelectrodes.\textsuperscript{7-10} Also, BiVO\textsubscript{4} possesses favorable conduction band and valence band positions for the water splitting reaction while having a bandgap that can absorb visible light.\textsuperscript{6, 11} Furthermore, its photostability for solar water splitting when paired with proper oxygen evolution catalysts has recently been demonstrated for several hundred hours, confirming the promise of BiVO\textsubscript{4} for sustainable PEC operation.\textsuperscript{12-13}

Based on these promising features, various doping studies have been performed to date to further enhance the photoelectrochemical properties of monoclinic BiVO\textsubscript{4} via composition tuning. Most commonly reported doping studies involve the modification of the vanadium site. For example, doping Mo\textsuperscript{6+} and W\textsuperscript{6+} ions on the V\textsuperscript{5+} site is known to increase the majority carrier density, which improves the electron transport properties and electron-hole separation.\textsuperscript{14-17} In addition, several studies on manipulating the oxygen site of BiVO\textsubscript{4} have been reported. For example, increasing oxygen vacancies in the BiVO\textsubscript{4} lattice by annealing under a reducing environment (e.g. under H\textsubscript{2} or N\textsubscript{2} flow) was shown to improve the majority carrier density of
Recently, it was also demonstrated that replacing oxygen with nitrogen can decrease the bandgap of BiVO$_4$ while improving its charge transport properties.\textsuperscript{21}

Compared to investigations of vanadium and oxygen sites of monoclinic BiVO$_4$, studies on the composition tuning of Bi sites have been relatively empirical; although changes in properties were reported after Bi-site doping, no elucidations have been made regarding how the dopants caused the observed modifications.\textsuperscript{22-26} To accurately elucidate the doping effect on the Bi site, confirmation of dopant incorporation in the lattice must be obtained first, so as to exclude the case of dopants accumulating at the surface. Another important prerequisite for a rigorous doping study is to ensure that the pristine and doped samples have comparable morphologies. If dopants added during the synthesis resulted in a change of morphology, it would be difficult to unambiguously determine the reason for the observed difference between the pristine and doped samples.

In this study, we report experimental and computational investigations of doping lanthanide ions (Ln: La, Ce, Sm, Yb) at the Bi sites of BiVO$_4$. The trivalent Ln ions have similar ionic size and coordination preference to those of Bi$^{3+}$. Therefore, they are expected to substitutionally replace Bi$^{3+}$ in the BiVO$_4$ lattice. While +3 is the most stable oxidation state for most Ln ions, some are also known to have mixed valencies depending on their structural and chemical environment (e.g. Ce$^{3+/4+}$, Sm$^{2+/3+}$, and Yb$^{2+/3+}$). Therefore, it is possible that these ions may exert different effects on the charge transport properties of BiVO$_4$, which are interesting to systematically elucidate. In order to satisfy the aforementioned requirements for meaningful doping studies, we identified synthesis conditions to prepare pristine and Ln-doped samples with comparable morphologies. Furthermore, the incorporation of Ln ions into the Bi site could be
unambiguously confirmed by X-ray diffraction that showed changes in cell parameters according to the size of the dopant ions incorporated in the BiVO$_4$ lattice.

Although lanthanide ions are known to have similar bonding natures and show similar chemistry, the lanthanide ions selected in this study exhibited different effects on the electronic band structure of BiVO$_4$. In addition to the effect of Ln doping, we also investigated how these dopants interact with oxygen vacancies, a common defect of BiVO$_4$. We demonstrate that understanding of the combined effect of lanthanide doping and oxygen vacancies is critical to accurately interpret the measured photoelectrochemical properties of lanthanide doped BiVO$_4$ photoelectrodes.

2. Experimental

*Synthesis of Lanthanide-doped BiVO$_4$.*

BiVO$_4$ was prepared by first electrodepositing precursor BiOI electrodes on a fluorine-doped tin oxide (FTO) working electrode, as described in previous reports. The BiOI electrodes were converted to BiVO$_4$ electrodes by annealing at 450 °C for 2 h in the air (ramping rate =1.8 °C/min) after covering the electrode surface (lateral dimensions of the BiOI electrode = 1 cm x 1.25 cm) with 75 μL of a dimethyl sulfoxide (DMSO) solution containing 0.15 M vanadyl acetylacetonate (VO(acac)$_2$). Excess V$_2$O$_5$ present in the BiVO$_4$ electrodes was removed by soaking the electrodes in 1 M KOH solution for 30 min with gentle stirring. The resultant Ln-BiVO$_4$ films were rinsed in DI water and dried under a gentle N$_2$ flow.

In order to produce Ln-doped BiVO$_4$, the BiOI electrodes were annealed using the above conditions after a 0.15 M VO(acac)$_2$ DMSO solution containing varying amounts of lanthanide nitrate precursors (La(NO$_3$)$_3$, Ce(NO$_3$)$_3$, Sm(NO$_3$)$_3$, and Yb(NO$_3$)$_3$) was added on the top. An
optimum concentration of the La, Ce, Sm and Yb precursors was 0.00075 M in the DMSO solution, which resulted in the production of BiVO$_4$ films that contain 2.5-3.0% Ln ions in the V site. After the synthesis, some lanthanide oxides were present in the edge area of the Ln-doped BiVO$_4$ electrodes, which was due to the lanthanide ions being concentrated in the edge of the drop-casted DMSO solution during annealing. However, they did not affect the characterization of the Ln-doped BiVO$_4$ electrodes, which was carried out using only the central region of the electrodes while masking the rest.

**Characterization.**

The purity and crystal structure of BiVO$_4$ and Ln-doped BiVO$_4$ were examined by powder X-ray diffraction (Bruker D8 Advanced PXRD, $\lambda = 1.5418$ Å, 298 K, Ni-filtered Cu K$_\alpha$ radiation. The morphology of the synthesized electrodes was examined with a scanning electron microscope (LEO 1530) operated at an accelerating voltage of 2 kV. The atomic composition of Ln-doped BiVO$_4$ was measured with a Thermo Fisher UltraDry EDS detector attached to the LEO 1530 scanning electron microscope at an accelerating voltage of 15 kV. Multiple locations of the multiple samples obtained by each synthesis condition were analyzed to confirm a consistent average composition. Ultraviolet-visible absorption spectra were obtained on an Agilent Cary 5000 spectrophotometer in which the sample was placed in the center of an integrating sphere to accurately assess the absorbance. X-ray photoelectron spectroscopy spectra were obtained using a Thermo Scientific K-Alpha X-ray photoelectron spectrometer with an Al K$_\alpha$ excitation source. The binding energies were calibrated with respect to the residual carbon 1s peak at 284.8 eV.

**Photoelectrochemical Measurements.**
Photoelectrochemical performances of the BiVO$_4$ and Ln-BiVO$_4$ electrodes used in this paper were evaluated in an undivided three-electrode configuration using an SP-200 potentiostat/EIS (BioLogic Science Instruments). Simulated solar light was obtained from a 300 W Xe arc lamp (Ushio America, Inc.), first passing through a water filter (IR filter), neutral density filters, and an AM1.5G filter. The light then passed through a fused silica fiber optic cable (Newport Instruments) and a collimating lens before reaching the sample (Newport) to achieve uniform light illumination. The samples were illuminated through the back (glass) side of the FTO substrate. The power density of the incident light was calibrated to 100 mW/cm$^2$ at the surface of the electrode backside, after the light passes through the FTO substrate, using a research radiometer (International Light, IL 1700) coupled to a thermopile detector (International Light, SED 623/HNK 15). The light spectrum was calibrated to match that of the solar spectrum using an NREL certified Si reference cell (Photo Emission Tech, Inc.).

Photoelectrochemical measurements were performed in 0.5 M potassium phosphate (KH$_2$PO$_4$) buffer solution at pH 7.3, with or without sodium sulfite as a hole scavenger. J-V performance under illumination was measured by sweeping the potential to the positive direction from the open circuit potential under illumination with a sweep rate of 10 mV/s. All measurements were carried out using a Pt counter electrode and Ag/AgCl reference electrode (4 M sat. KCl), though all results are presented against the reversible hydrogen electrode (RHE) for ease of comparison against the water oxidation and reduction potentials at the specified pH. The potential was converted from Ag/AgCl to RHE using the following equation.

\[
E_{\text{vs. RHE}} = E_{\text{vs. Ag/AgCl}} + E_{\text{Ag/AgCl (reference)}} + 0.0591 \, V \times \text{pH}
\]

\[
(E_{\text{Ag/AgCl (reference)}} = 0.1976 \, V \text{ vs. NHE at } 25 \, ^\circ\text{C})
\]
Capacitance measurements for Mott-Schottky plots were obtained using the same aforementioned three electrode cell configuration and SP-200 potentiostat/EIS (BioLogic Science Instrument). The measurements were taken in a 0.5 M potassium phosphate (KH$_2$PO$_4$) buffer solution at pH 7.3. A sinusoidal modulation of 10 mV was applied at frequencies of 0.5 and 1 kHz. All electrodes were masked to the same geometric area of ~0.2 cm$^2$ for this measurement.

*Electronic Structure Calculations.*

Spin-polarized density-functional theory (DFT) calculations were performed using plane-wave basis sets with the Quantum ESPRESSO package. We used exchange-correlation functionals within the Perdew-Burke-Ernzerhof generalized gradient approximation (PBE) and pseudopotentials within the projector-augmented wave (PAW) method. We included Hubbard $U$-corrections to the $d$ electrons of V, $U$(V)=2.7 eV as used in previous studies, and to the $f$ electrons of the lanthanide atoms, $U$(Ln)=5.0 eV, which is in the range of 2.5--5.5 eV suggested, e.g. by Topsakal et al. We used a (2x1x2) supercell of BiVO$_4$ with 96 atoms; one Bi atom of the supercell was replaced with a Ln atom, corresponding to a doping concentration of 6.25% at the Bi site. The effects of O vacancies were also considered in our calculations; we simulated the O vacancies by removing one O atom from the supercell, which correspond to a defect concentration of ~1.56%. A (5x6x6) Monkhorst-Pack k-point grid was employed to sample the Brillouin zone.

3. Results and Discussion

*Experimental results and discussions.*
Nanoporous BiVO$_4$ electrodes used in this study were synthesized using a previously reported method where electrodeposited BiOI films were used as precursor films.$^7$ A typical SEM image of the BiOI films used for the synthesis is shown in Figure 1a. BiOI films were converted to BiVO$_4$ electrodes by covering the electrode with a DMSO solution containing vanadyl acetylacetonate as the vanadium source and heating it at 450 °C in the air. Unreacted vanadium ions that formed V$_2$O$_5$ on the BiVO$_4$ surface could be easily removed by immersing the film in 1 M NaOH for 30 minutes.

![Figure 1. SEM images of (a) BiOI, (b) pristine BiVO$_4$, (c) La-doped BiVO$_4$, (d) Ce-doped BiVO$_4$, (e) Sm-doped BiVO$_4$, and (f) Yb-doped BiVO$_4$.](image)

This synthesis method also allowed for the preparation of Ln-doped BiVO$_4$ electrodes by simply adding the lanthanide of interest (La, Ce, Sm, and Yb) as part of the vanadium solution.
used to convert BiOI to BiVO₄. The concentration of lanthanide ions in the vanadium solution was varied to result in Ln-doped BiVO₄ electrodes where the content of Ln (mol of Ln/mol of (Bi+Ln)) is 0.025-0.030. (In other words, 2.5-3% Bi in the Bi sites is replaced by Ln ions.) The content of Ln ions in doped BiVO₄ samples were determined using energy dispersive X-ray spectroscopy (EDS).

This synthesis method ensured that the morphology and particle size of the pristine and doped BiVO₄ electrodes are comparable (Figure 1b-f). This enabled us to assume that lanthanide doping is solely responsible for the difference observed in any properties or performances between pristine and doped BiVO₄ electrodes.

The fact that the lanthanide ions indeed substitutionally replaced Bi³⁺ in the BiVO₄ lattice could be confirmed by comparing XRD patterns of pristine and doped BiVO₄ films (Figure 2a). The addition of all lanthanide dopants did not change the overall monoclinic crystal structure of BiVO₄ or generate impurity peaks. However, close analysis of the X-ray patterns showed that Bragg peaks of BiVO₄ shifted to higher two theta values, which corresponds to a decrease in lattice parameters, upon doping. This is expected for substitutional replacement of Bi³⁺ ions with Ln³⁺ ions because Ln³⁺ ions are smaller than Bi³⁺ ions. (If Ln³⁺ is present in the interstitial sites or replaces V⁵⁺, a decrease in cell parameters cannot be expected.) The trend for the shift to higher two theta values also matched very well with the size trend in the Ln³⁺ ions. La³⁺ and Ce³⁺, which possess ionic radii that are only slightly smaller than Bi³⁺ (1.16 Å and 1.14 Å compared to 1.17 Å, respectively) showed a relatively small change in lattice parameters upon doping. Conversely, Sm³⁺ and Yb³⁺ possess ionic radii much smaller than that of La and Ce (1.08 Å and 0.98 Å, respectively) and correspondingly showed a larger decrease in lattice parameters and peak positions. The shifts of (1-12) and (004) peaks appearing at two theta values of 28.9° and 30.5°,
respectively, are shown as examples in Figure 2b. These results unambiguously confirm that the Ln doping resulted in the replacement of Bi$^{3+}$ ions with Ln$^{3+}$ ions.

Figure 2. (a) XRD patterns of pristine (black) and doped BiVO$_4$: La (pink), Ce (green), Sm (red), and Yb (blue). Peaks were indexed according to JCPDS card 83-1699. (b) Magnified spectra showing the shifts of a few selected Bragg peaks.

The UV-visible absorbance spectra for the Ln-doped BiVO$_4$ show that Ln doping induced little change in light absorption of BiVO$_4$ (Figure 3). The major bandgap transition is seen to begin at ~520 nm in all lanthanide-doped samples and pristine BiVO$_4$. However, in the case of Ce-doped BiVO$_4$, an absorption tail below the bandgap energy exists, suggesting the presence of interband states in the bandgap region. Photoelectrochemical properties of this sample, which are
discussed below, show that this interband absorption did not contribute to an increase in photocurrent.

![Absorbance spectra](image)

**Figure 3.** UV-visible absorbance spectra of pristine (black) and doped BiVO$_4$: La (pink), Ce (green), Sm (red), and Yb (blue).

The current density-potential (J-V) characteristics of the Ln-doped films were examined and compared to that of pristine BiVO$_4$ using photooxidation of sulfite to probe the effects of doping on charge transport and electron-hole separation. Sulfite ion was employed as a hole scavenger because of its fast oxidation kinetics. Since sulfite oxidation can consume almost all the surface reaching holes, any change in photocurrent density for sulfite oxidation after Ln doping can be directly related to the change in the number of surface-reaching holes or the yield for electron-hole separation.

The J-V plots in Figure 4a show that Ce doping is detrimental to photocurrent generation of BiVO$_4$. La doping also resulted in a decrease in photocurrent generation although the decrease is not as considerable as that caused by Ce doping. Conversely, Sm and Yb doping slightly enhanced the photocurrent.
Figure 4. (a) J-V plots for sulfite oxidation under AM 1.5G, 100 mW/cm$^2$ illumination for undoped (black) and doped BiVO$_4$ samples: La (pink), Ce (green), Sm (red), and Yb (blue). The measurement was performed in 0.5 M phosphate buffer (pH 7.3) containing 1 M Na$_2$SO$_3$ using a scan rate of 10 mV/s. (b) J-V plots for water oxidation obtained in 0.5 M phosphate buffer (pH 7.3). The average photocurrent densities with standard deviations obtained with five different samples for each case can be found in Tables S1-2.

The J-V plots were also measured for photooxidation of water (Figure 4b). Since water oxidation kinetics are poor on the BiVO$_4$ surface, the photocurrent obtained for water oxidation was generally lower than that of sulfite oxidation for all samples. However, a nearly identical trend for photocurrent generation due to the dopants was observed for water oxidation as was seen for sulfite oxidation. This suggests that any of the Ln dopants is not particularly catalytic for water oxidation and the trend of photocurrent for water oxidation was mainly affected by Ln dopants altering charge transport and electron-hole recombination in BiVO$_4$. 
In order to investigate the effect of Ln doping on the majority carrier concentration of BiVO$_4$, Mott-Schottky plots of pristine and doped BiVO$_4$ electrodes were obtained at two different frequencies in 0.5 M phosphate buffer (pH 7.3) (Figure 5 and Table S3). As the BiVO$_4$ electrodes used in this study have nanoporous morphologies and their true surface areas are not known, accurate determination of the carrier density of these electrodes was not possible. However, since all of the doped and pristine samples have comparable morphologies and surface areas, the change in slope of the Mott-Schottky plots could still be used to qualitatively compare carrier densities of these electrodes.

![Figure 5](image)

**Figure 5.** Mott-Schottky plots for pristine (black) and doped BiVO$_4$ (La (pink), Ce (green), Sm (red), and Yb (blue)) measured in 0.5 M phosphate buffer at two different frequencies, (a) 0.5 kHz and (b) 1 kHz. The average slopes with standard deviations obtained with five different samples for each case can be found in Table S3.

The results show a slight frequency dependence but the trends shown in each frequency are consistent. The La- and Ce- doped samples show slopes that are similar to those of pristine BiVO$_4$. This means that the decreased photocurrent observed with La and Ce-doped samples are not due to a decrease in carrier density but due to other effects. The Sm- and Yb-doped samples show slopes that are approximately half of the slopes observed in the pristine sample (Table S3). This suggests that the enhanced photocurrent observed with Sm- and Yb-doped samples are related to an increase in carrier density in these samples.
The oxidation states of the dopants as well as any changes in the oxidation state of the host elements were examined by XPS, which are critical to understand the doping effects. In all lanthanide-doped samples, the positions of the Bi 4f peaks and V 2p peaks were all found to be unchanged relative to pristine samples within the instrument error of 0.1 eV (Supplementary Figure S1). This suggests that Ln doping did not considerably affect the oxidation states and bonding environments of the Bi$^{3+}$ and V$^{5+}$ ions.

The La 3d peaks of the La-doped BiVO$_4$ are shown in Figure 6a. These peak positions (835.6 eV for 3d$_{5/2}$ and 839.2 eV for 3d$_{3/2}$) match very well with those of La$^{3+}$ in La$_2$O$_3$, confirming the presence of La only in the +3 oxidation state in the Ln-doped BiVO$_4$ lattice.\textsuperscript{35-36} The Ce 3d peaks of the Ce-doped BiVO$_4$ show doublets for both 3d$_{5/2}$ (881.7 eV and 885.5 eV) and 3d$_{3/2}$ peaks (900.2 eV and 904.3 eV), which are typical peak shapes and positions expected for Ce$^{3+}$ (Figure 6b).\textsuperscript{24,37} The Ce 3d peaks of CeO$_2$, which contains only Ce$^{4+}$ are also shown for comparison. Ce$^{4+}$ peaks are composed of multiplets for both 3d$_{5/2}$ and 3d$_{3/2}$, which overlap with doublets for 3d$_{5/2}$ and 3d$_{3/2}$ of Ce$^{3+}$. Therefore, easy differentiation of Ce$^{4+}$ and Ce$^{3+}$ peaks may be difficult. However, a peak appearing at 917 eV can be used as an unambiguous indication for the presence of Ce$^{4+}$ ions.\textsuperscript{37} Therefore, the lack of a Ce$^{4+}$ peak at 917 eV in the spectrum of the Ce-doped sample confirms that Ce dopants in the Ce-doped BiVO$_4$ are all stabilized in the +3 oxidation state.

The fact that both La and Ce dopants are present in the 3$^+$ oxidation states confirm that substitutional La and Ce doping on Bi sites are isovalent doping and, therefore, a change in majority carrier density of BiVO$_4$ is not expected. This result agrees well with the result obtained by the Mott-Schottky plots. This also means that the decrease in photocurrent obtained with La and Ce-doped samples is not due to the carrier concentration change but through other
mechanisms such as change in mobility or the presence of interband states affecting electron-hole recombination.

![Figure 6](image.png)

Figure 6. XPS of (a) La 3d peaks in La-doped BiVO$_4$ (pink) and in La$_2$O$_3$ (black), (b) Ce 3d peaks in Ce-doped BiVO$_4$ (green) and CeO$_2$ (black), (c) Sm 3d peaks in Sm-doped BiVO$_4$ (red) and Sm$_2$O$_3$ (black), and (d) Yb 4d peaks in Yb-doped BiVO$_4$ (blue) and Yb$_2$O$_3$ (black).

The Sm 3d peak of the Sm-doped BiVO$_4$ appeared at 1083.1 eV and 1109.8 eV, which are major peaks of 3d$_{5/2}$ and 3d$_{3/2}$, respectively (Figure 6c). The positions and shapes of these peaks match well with those of Sm$^{3+}$ in Sm$_2$O$_3$ used as a reference. There is an additional peak appearing at 1090.7 eV only with the Sm-doped sample. This peak, which is known as an energy loss satellite peak of 3d$_{5/2}$, is also associated with +3 oxidation state of Sm. The presence of Sm$^{2+}$ in the Sm-doped sample is unlikely because of the absence of characteristic peaks for Sm$^{2+}$ that are reported to appear at ~1074 eV and ~1096 eV in the literature. Therefore, it was concluded that Sm ions in the Sm-doped sample are present as Sm$^{3+}$, meaning that Sm doping is
also isovalent doping. As mentioned above, isovalent doping cannot change the majority carrier density. Therefore, the discrepancy between the Mott-Schottky results and XPS results suggests that Sm doping most likely affected other features of BiVO₄, such as the concentration of oxygen vacancies, to alter the charge carrier density of BiVO₄ and enhance photocurrent.

In the case of Yb-doped BiVO₄, however, both Yb³⁺ and Yb²⁺ ions appear to be present. For Yb₂O₃, which contains only Yb³⁺ ions, the two most intense peaks associated with 4d electrons are found at 185.3 eV and 199.5 eV, which are attributed to the 4d₅/₂ and 4d₃/₂ spin states, respectively. These peaks each have shake-up lines that are found at ~193.2 eV and 206.0 eV, about 6-7 eV higher than the main spin state features. Compared to the 4d₅/₂ peak of Yb₂O₃, the 4d₅/₂ peak of the Yb-doped sample shows two shoulder peaks at 181.8 eV and 189.7 eV, which are unlikely to be associated with the Yb³⁺ oxidation state. Although we were unable to find 4d₅/₂ peaks of Yb²⁺ stabilized in the oxide matrix reported in the literature, we note that there are reports of 4d₅/₂ peaks of Yb²⁺ at ~181.5 eV and ~190.1 eV in intermetallic compounds containing the Yb²⁺ oxidation state. Therefore, these shoulder peaks may indicate the presence of Yb²⁺ ions in the Yb-doped sample. However, it is not certain whether the presence of Yb²⁺ is directly related to the observed carrier density increase of the Yb-doped sample. Therefore, DFT calculations were performed to construct electronic band structures of Ln-doped BiVO₄ so that the relationship between Ln-doping and all the aforementioned experimental results can be further elucidated.

**DFT calculations on Ln Doping.**

**Results for La doping.** For La-doped BiVO₄ we found that the presence of La atoms does not affect the band structure of the system, as shown in Figure S2; we obtained an indirect band gap of ~2.31 eV for La-BiVO₄ similar to the band gap computed for pristine BiVO₄ (~2.27 eV);
the slight increase in the band gap is due to a minor downward shift of the valence band minimum (VBM). However, this change is negligible and we do not expect it will be responsible for a difference in photon absorption, as shown in Figure 3. We note that the major electronic state contributions from the La dopant are located deep in the conduction band, far from the band edges and the band gap region (see Figure S2). Therefore, the decrease in photocurrent observed experimentally in the La-doped samples cannot be explained using only the results of the La doped band energies.

In order to examine whether La doping affected the mobilities of charge carriers, we computed the effective masses of holes and electrons in pristine and La-doped BiVO$_4$, as well as in the other doped systems. The effective masses were computed from quadratic fits of the bands. We found significant increases in the effective masses of both electrons and holes in La- and Ce-doped BiVO$_4$. For example, the effective mass of holes was found to increase by 24% (33%) in La-(Ce-) doped BiVO$_4$ compared to that of the pristine system. The presence of heavier carriers in La-BiVO$_4$ and in Ce-BiVO$_4$ may be one of the reasons for the reduced photocurrent observed in these systems. We found that the effective masses of carriers in Yb- and Sm-BiVO$_4$ are also slightly heavier than those of pristine BiVO$_4$, although lighter than those in La- and Ce-BiVO$_4$ (see Table S4).

**Results for Ce doping.** For Ce-doped BiVO$_4$ we found an indirect band gap of $\sim$2.30 eV, almost the same as that of pristine BiVO$_4$. Overall, the band structure of Ce-doped BiVO$_4$ was found to be similar to that of pristine BiVO$_4$ (see Figure 7(a)), except for an occupied state in the gap, at about 0.5 eV above the VBM. The filled state in the midgap region, which is mainly composed of Ce f orbitals (Fig. 7(b)), may act as a recombination center when electron-hole pairs are generated: when holes are generated in the valence band, they may recombine with
electrons occupying the midgap state, which, if left empty, may then be filled by an electron initially excited to the conduction band. The net effect is a recombination process involving the mid-gap state, which is one of possible processes explaining the reduced photocurrent observed in the Ce-doped samples.

Figure 7. (a) Band structures of pristine and Ce-doped BiVO₄; the band structures were aligned using the position of the 3s energy levels of a V atom located far from the dopant and the reference energy was set at the Fermi level of the doped system. (b) Projected density of states (PDOS) of Ce-doped BiVO₄, spin up in the right panel and spin down in the left panel. Note that the spin-up and spin-down state are indistinguishable in our calculations and both spin-up and spin-down states are present in the real material.

We note that our results showing the formation of a filled state in the midgap region in the presence of Ce doping are consistent with those previously reported by Jiang et al. However, while our experimental results show a photocurrent decrease by Ce doping, Jiang at al. reported a photocurrent enhancement by Ce doping. As we mentioned previously, doping may lead to different outcomes if it is accompanied by changes in morphology, surface area, and crystallinity of the host material. The effect of Ce doping can be explicitly and accurately determined only when it is achieved without changing other materials properties. Our SEM and
XRD results confirmed that the Ce doping in our samples was achieved without inducing a change in morphology and crystallinity and that Ce was truly incorporated into the BiVO$_4$ lattice.

We also found that holes and electrons in Ce-doped BiVO$_4$ have the largest effective masses among all the doped systems considered here. As shown in Table S4, the effective masses of holes (electrons) increase by 33% (11%) in Ce-doped BiVO$_4$ compared to those of pristine BiVO$_4$. These results point at lower carrier mobilities in Ce-doped BiVO$_4$ when compared to those of other systems investigated here, which may be one of the reasons for the reduced photocurrent measured in the Ce-doped samples.

**Results for Sm and Yb doping.** For both Yb-doped and Sm-doped BiVO$_4$ we found indirect band gaps of ~2.3 eV (similar to the band gap of pristine BiVO$_4$) and no significant shifts in the valence and conduction band edges with respect to those of the pristine system (see Figs. 8(a) and 9(a)). In both systems we found unoccupied states in the band gap region: in Yb-BiVO$_4$ (Fig. 8) we observed the presence of an isolated empty band at about 1.5 eV below the conduction band minimum (CBM), mainly composed of Yb $f$ states; in Sm-BiVO$_4$ (Fig. 9) we found two unoccupied bands between 0.4 and 0.9 eV below the CBM, which mainly originate from Sm $f$ states. However, the presence of these empty interband states in the midgap region cannot explain the enhanced photocurrent or the increased carrier concentration of Yb- and Sm-doped samples. We then turned to study possible effects originating from the combined presence of dopants and oxygen vacancies.
Figure 8. (a) Band structures of pristine and Yb-doped BiVO$_4$; the band structures were aligned using the position of the $3s$ energy levels of a V atom located far from the dopant and the reference energy was set at the Fermi level of the doped system. (b) Projected density of states (PDOS) of Yb-doped BiVO$_4$, spin up in the right panel and spin down in the left panel.

Figure 9. (a) Band structures of pristine and Sm-doped BiVO$_4$; the band structures were aligned using the position of the $3s$ energy levels of a V atom located far from the dopant and the reference energy was set at the Fermi level of the doped system. (b) Projected density of states (PDOS) of Sm-doped BiVO$_4$, spin up in the right panel and spin down in the left panel.

**DFT calculations on the combined effect of Ln Doping and O vacancy.** Oxygen vacancy is an intrinsic defect in BiVO$_4$ and may interact with extrinsic Ln dopants. For example, a joint theoretical and experimental study recently showed that the combined effect of nitrogen doping
and the generation of O vacancies can improve the performance of BiVO$_4$ for solar water splitting.$^{21}$ Therefore, we investigated the interaction of Ln doping and O vacancy. We considered one O vacancy in a supercell with 96 atoms (64 O atoms), which corresponds to a concentration of $\sim$1.56%. In pristine BiVO$_4$ (Fig. S3), we found that the presence of O vacancy leads to the formation of a localized filled state in the midgap region, at $\sim$1.4 eV above the VBM; no changes in the band gap and in the band edge positions were observed, in agreement with our previous study (Figure 10a-b).$^{21}$ For both La- and Ce-doped BiVO$_4$ we found that combining O vacancy with doping resulted in a straightforward addition of the two effects, with no interaction or synergy among them (see Figure S3).

**Figure 10.** Projected density of states (PDOS) of (a) pristine BiVO$_4$, (b) BiVO$_4$ with O vacancy, (c) Sm-doped BiVO$_4$ with O vacancy and (d) Yb-doped BiVO$_4$ with O vacancy. Spin up in the right panel and spin down in the left panel.

Interestingly, when an O vacancy was combined with Sm or Yb doping, the resulting band structure was more complex (Figure 10c-d). The empty midgap states observed in the case
of Sm or Yb doping alone are no longer present, and new filled midgap states are present near the CBM, which may serve as donor states (Figure 10c-d). These filled states have mainly a lanthanide $f$ character and are located between 0.3 and 1.0 eV below the CBM in Yb-doped BiVO$_4$, and between 0.1 and 0.3 eV below the CBM in Sm-doped BiVO$_4$. We also found additional filled states with oxygen character, positioned lower in energy, relative to the CBM, than the $f$ lanthanide states (Figure 10c-d). These states are also lower in energy than the filled midgap state formed by O vacancy alone (Figure 10b).

These results suggest that although Sm or Yb doping alone does not provide donor states and hence does not increase carrier densities, the combination of Sm or Yb doping with O vacancies may give rise to donor states that are different from those formed by O vacancies alone. In particular, these states are closer to the CBM and hence, in principle, easier to ionize; thus they may be responsible for the higher carrier density shown in the Mott-Schottky plots as well as for the enhanced photocurrent caused by Sm and Yb doping. Although further investigations are necessary to come to definitive conclusions, including a study of polarons in the doped material, our results on the electronic states clearly demonstrate the effect of the interaction of intrinsic defects, in particular oxygen vacancies, and extrinsic dopants.

**Conclusions**

In summary, we found that substitutional doping at the Bi$^{3+}$ site with La, Ce, Sm, and Yb resulted in several unique changes in the photoelectrochemical properties of BiVO$_4$. Enhancements in the photoelectrochemical oxidation of sulfite and water were found in the cases of Sm and Yb and the opposite effect was observed in the case of La and Ce. These effects can be explained by changes in the electronic structure of the doped BiVO$_4$ compared to the pristine
one, as elucidated by DFT calculations. La doping was found to decrease the performance due, at least in part, to a significant increase in the effective masses of electrons and holes, thus leading to a possible decrease in carrier mobilities of BiVO₄. Ce doping was found to severely limit the performance of the material, due to the combined effect of increased effective masses of electrons and holes and the formation of a filled midgap state near the VBM, which likely acted as a recombination center for photogenerated electron-hole pairs. Sm and Yb doping led instead to an increase in carrier density which was interpreted as arising from donor states present below the CBM, which were found in DFT calculations when both dopants and oxygen vacancies were considered to coexist in the sample. The donor states obtained by the simultaneous consideration of Sm/Yb doping and O vacancy, which was critical for the interpretation of the experimental results, could not be obtained by the simple addition of the changes caused by Sm/Yb doping alone and O vacancy alone. This understanding may serve as a useful guideline for studying doped oxides where O vacancies are known to be intrinsic, common defects.

Associated Content

Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: XPS, supplementary band structures, and tables summarizing changes caused by Ln doping in photocurrent generation, Mott-Schottky plots, and effective masses of electrons and holes.

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